

# CURING WITH MULTI- WAVELENGTH LEDS

Radtech NA, 3/9/2020, Orlando, FL

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# AGENDA

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## 1 | OVERVIEW

- › Technology Comparison
- › Current status of Deep UV (DUV) LEDs

## 2 | EXPERIMENTAL SETUP

- › Lamps and chemistries
- › Nitrogen inerting
- › Physical tests

## 3 | RESULTS

- › Marginal Success Points (MSP) and Marginal Success Curve (MSC) for each formulation

## 4 | CONCLUSIONS

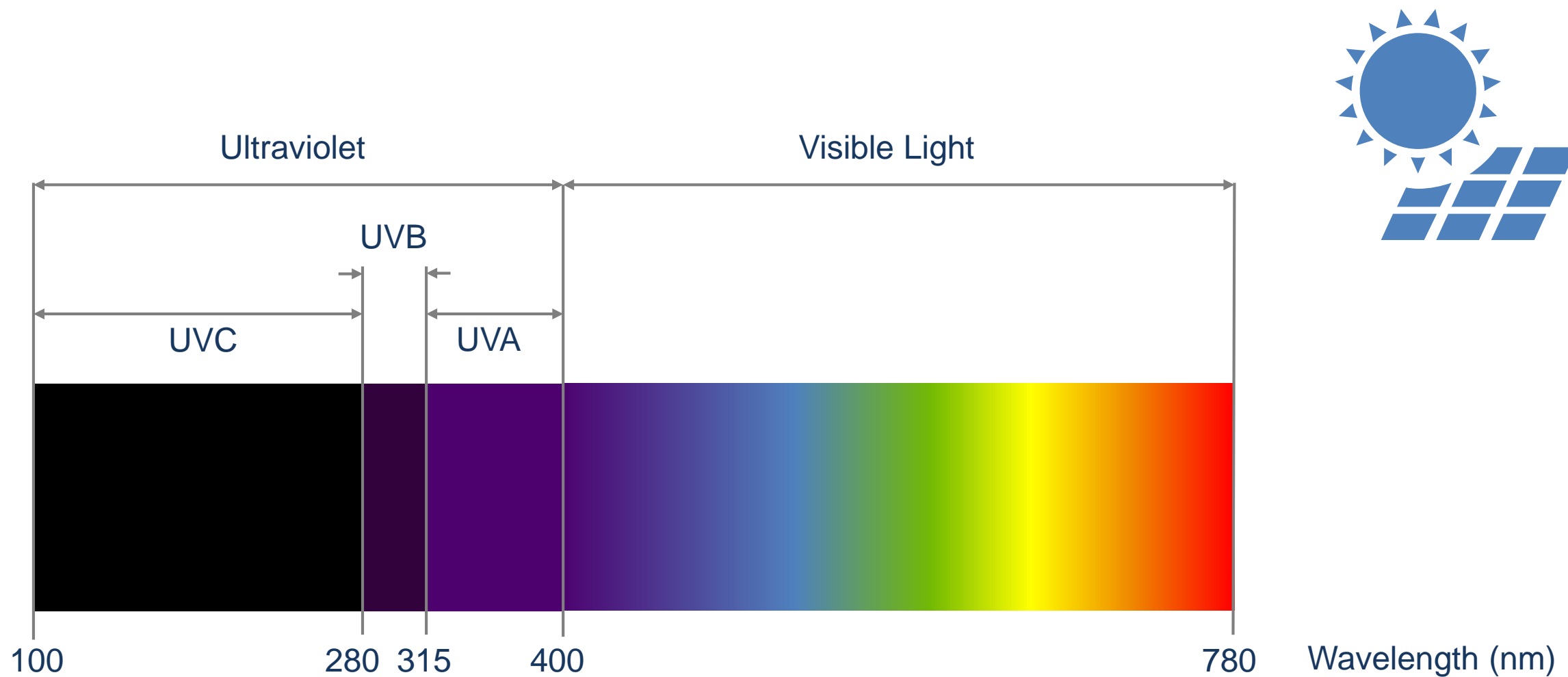
## 5 | DISCUSSION

- › Oxygen inhibition considerations
- › Future outlook

## 6 | QUESTIONS

# OVERVIEW

# OVERVIEW- UV SPECTRUM



# OVERVIEW- TECHNOLOGY

## Microwave-Powered Hg



### Advantages

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- › Mature technology
- › Fast process speed
- › Low cost of ownership
- › Working distance >50mm

### Drawbacks

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- › High electrical power consumption
- › Requires large blowers
- › Ozone formation
- › Presence of Hg

## LED Technology



### Advantages

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- › Instant on-off
- › Hg free
- › Long life
- › No blowers

### Drawbacks

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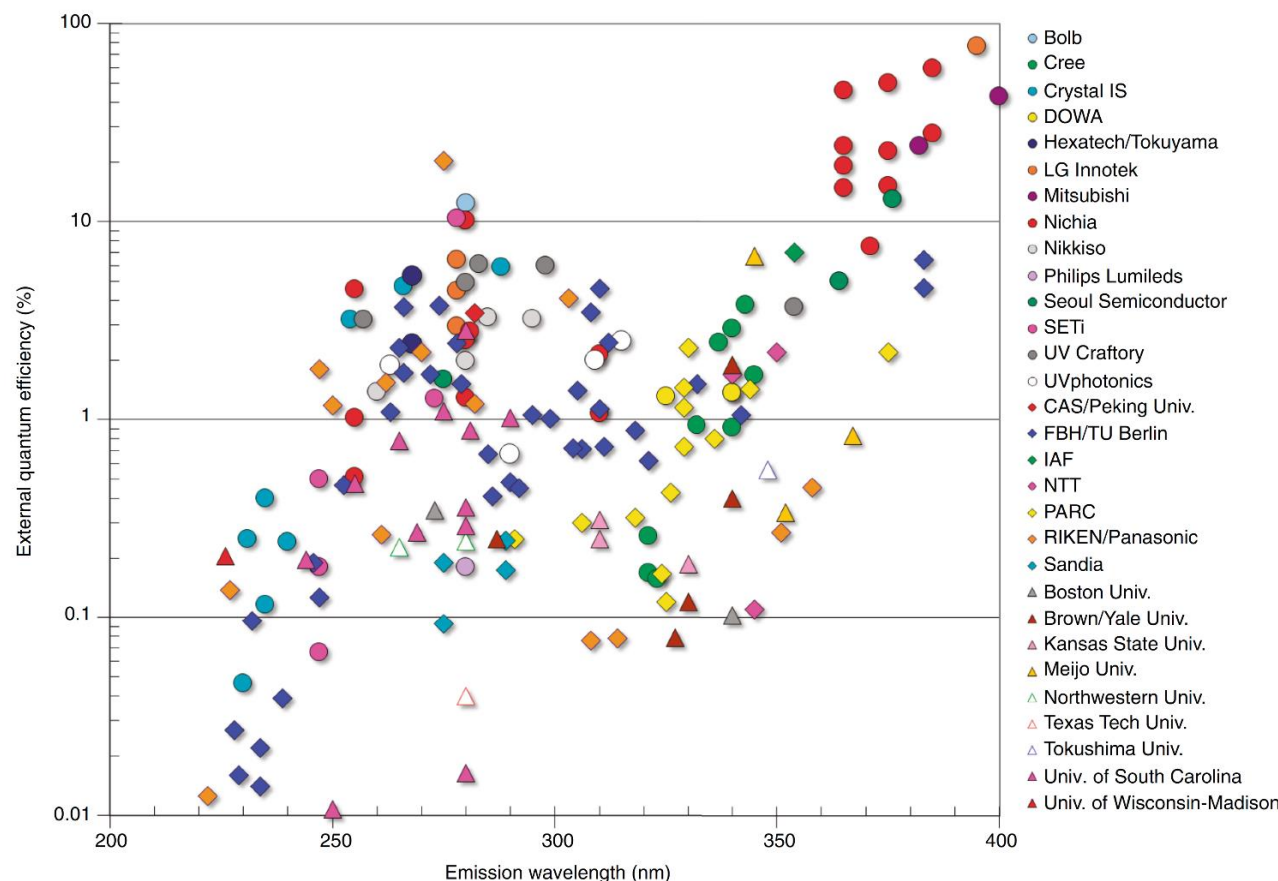
- › Newer technology
- › Limited wavelength choices
- › Low efficiencies at shorter  $\lambda$ s
- › Generally need close working distance of a few mm



# OVERVIEW- CURRENT STATE OF DUV LEDs



## EQEs for group-III-nitride-based LEDs



Kneissl, M., Seong, T., Han, J. et al. The emergence and prospects of deep-ultraviolet light-emitting diode technologies. Nat. Photonics 13, 233–244 (2019). <https://doi.org/10.1038/s41566-019-0359-9>

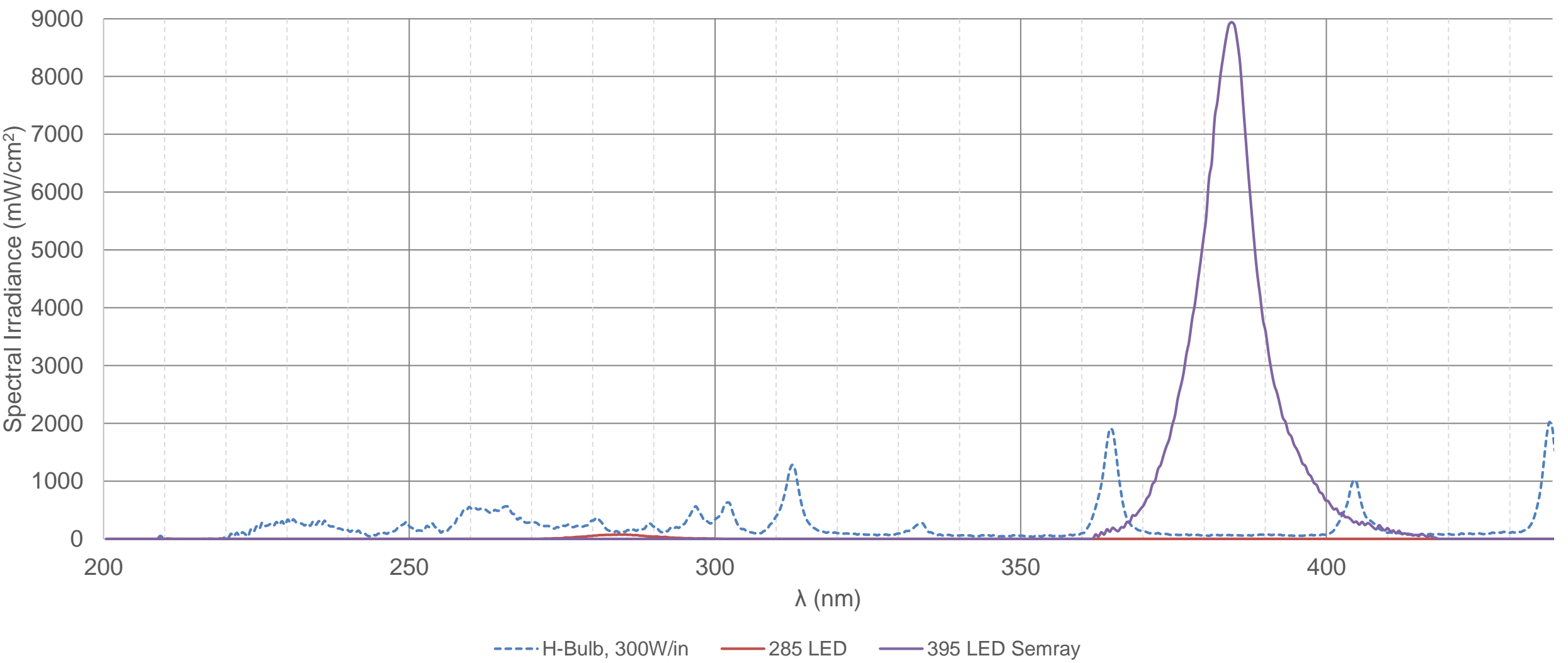
## External Quantum Efficiency

- › EQE of UVA LEDs (InGaN-based) is 46-76%
- › EQE of DUV LEDs (AlGaN-based) is 20% max at 275nm
- › Sharp drop in EQEs at wavelengths shorter than 250nm
- › Significant dip across UVB band
- › EQE and WPE for commercially available UVC LEDs is only 6.4% and 4.1%, respectively

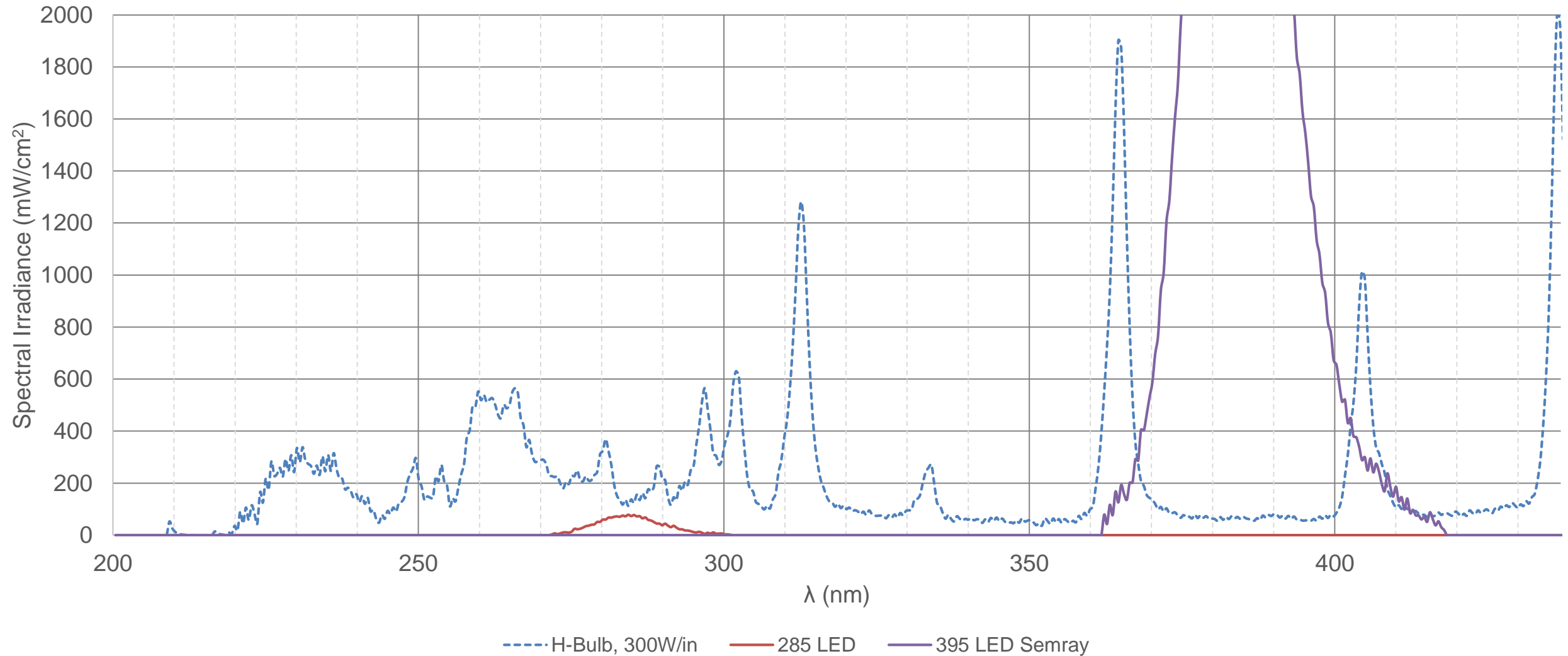
# EXPERIMENTAL SETUP



# EXPERIMENTAL SETUP- SPECTRAL IRRADIANCE OF SOURCES



# EXPERIMENTAL SETUP- SPECTRAL IRRADIANCE OF SOURCES



# EXPERIMENTAL SETUP- FORMULATIONS

## Coating A- Direct-to-metal (DTM), clear, 26µm DFT

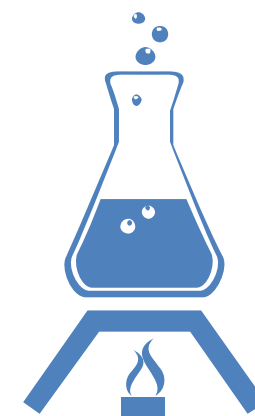
10.0%	SC 5242 (acrylic oligomer - Miwon)
24.0%	PE 2120B (80% epoxy acrylate, 20% TPGDA - Miwon)
7.0%	Ebecryl 4827 (aromatic urethane acrylate - Allnex)
15.0%	IBOA (monomer)
32.5%	TPGDA (monomer)
3.0%	SC 1400 (acidic adhesion promoter - phosphate methacrylate - Miwon)
0.25%	Byk 333 (wetting agent - Byk)
0.25%	Byk UV 3500 (surface slip additive - Byk)
2.5%	CPK/Irgacure 184 (photoinitiator - Rahn)
2.5%	DMHA/Darocure 1173 (photoinitiator - Rahn)
2.5%	MBF (photoinitiator - Rahn)
0.5%	TPO (photoinitiator - Rahn)

## Coating C- Clear, on Leneta cards, 14µm

45%	Ebecryl 221
40%	Ebecryl 85
10%	Ebecryl P115
2.5%	TPO
2.5%	Irgacure 184

## Coating B- Direct-to-metal (DTM), pigmented, 26µm DFT

43.3%	S5257 (Miwon)
27.9%	IBOA (Genomer 1121 Rahn)
9.6%	EOTMPTA (M3130 Miwon)
7.7%	SR 9051 (Sartomer)
4.8%	TPO (Rahn)
2.9%	Irgacure 500 (IGM)
3.8%	Plasticolors 73-02339 Black Dispersion



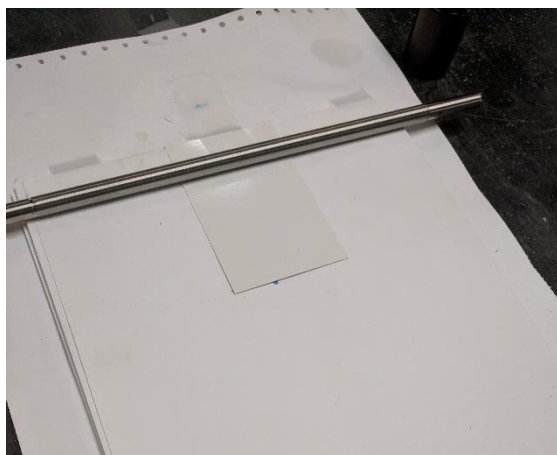
## Coating D- Clear, on Leneta cards, 14µm

75%	Ebecryl 5781
20%	Ebecryl LED 02
2.5%	TPO
2.5%	Irgacure 184

# EXPERIMENTAL SETUP

## Drawdown

- › Drawdown rod was used to apply a uniform thickness to the substrate



## Exposure

- › Nitrogen inerting was used for many samples ( $<100\text{ppmO}_2$ )
- › All samples were first exposed to 395nm then 285nm



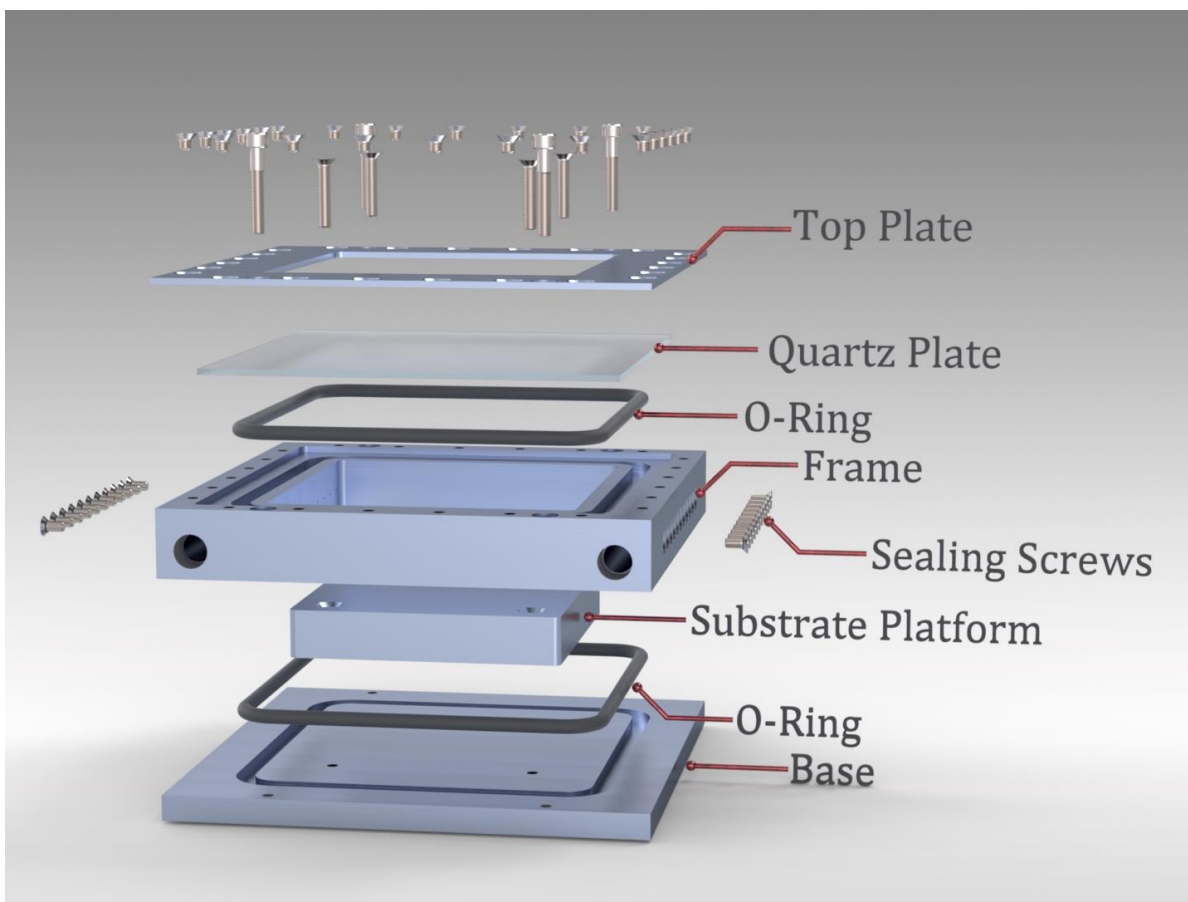
## Physical Tests

- › Thumb twist for “bulk cure”
- › MEK double rub for chemical resistance
- › Marginal success points (MSP) were found for various levels of UVA and UVB exposures

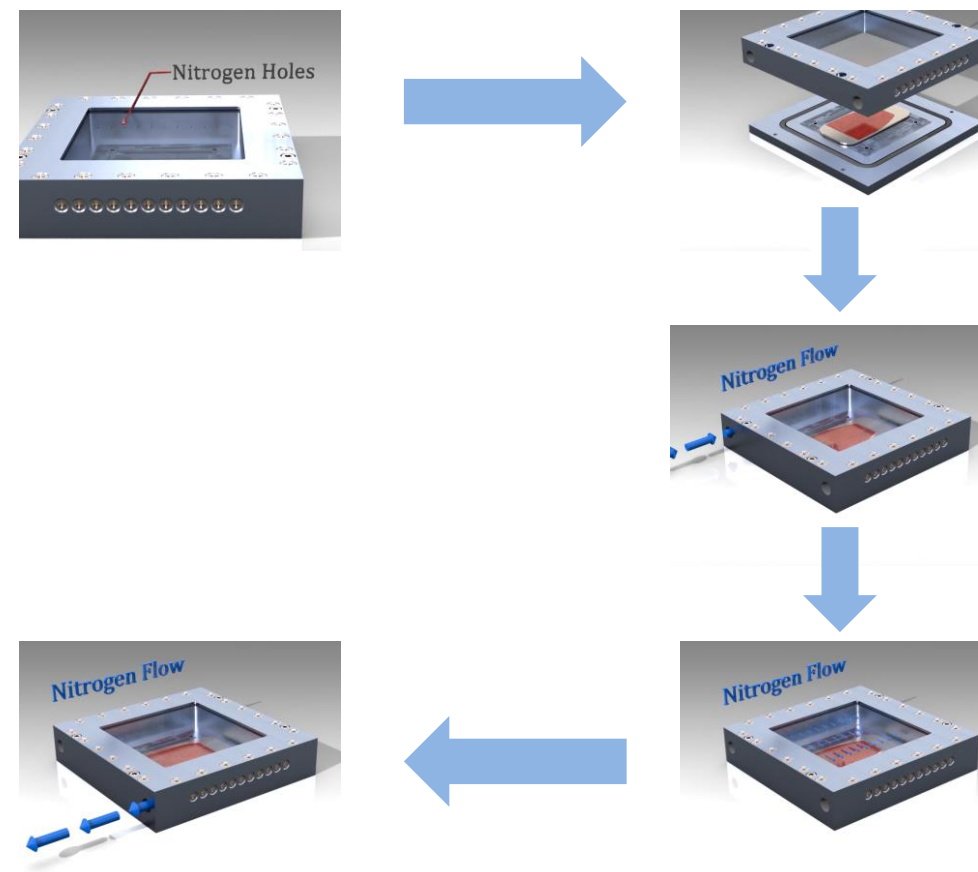


# EXPERIMENTAL SETUP- NITROGEN INERTING BOX

## Exploded View



## How It Works



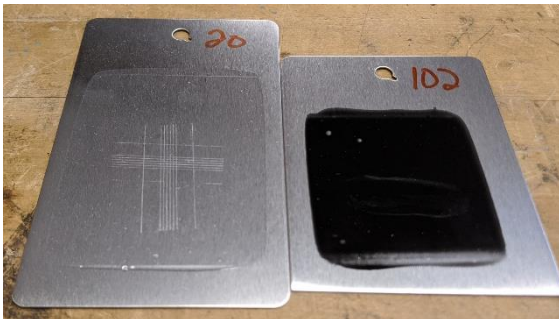
# RESULTS



# RESULTS- GENERAL

## Coatings A and B

- › DTM, Clear (A) and pigmented (B), 26 $\mu$ m (1mil)
- › Did not cure in air at minimal belt speeds (up to 500mJ/cm<sup>2</sup> UVB and 6,000mJ/cm<sup>2</sup> UVA)
- › Cured in N<sub>2</sub> at fast speeds/low exposures
- › Marginal success curve (MSC) plotted for MEK double rub in N<sub>2</sub>
- › Cured with only UVA or only UVB at high exposures, and cured with a combination of both at lower exposures
- › Using more UVA energy means less UVB is necessary to cure, and vice versa



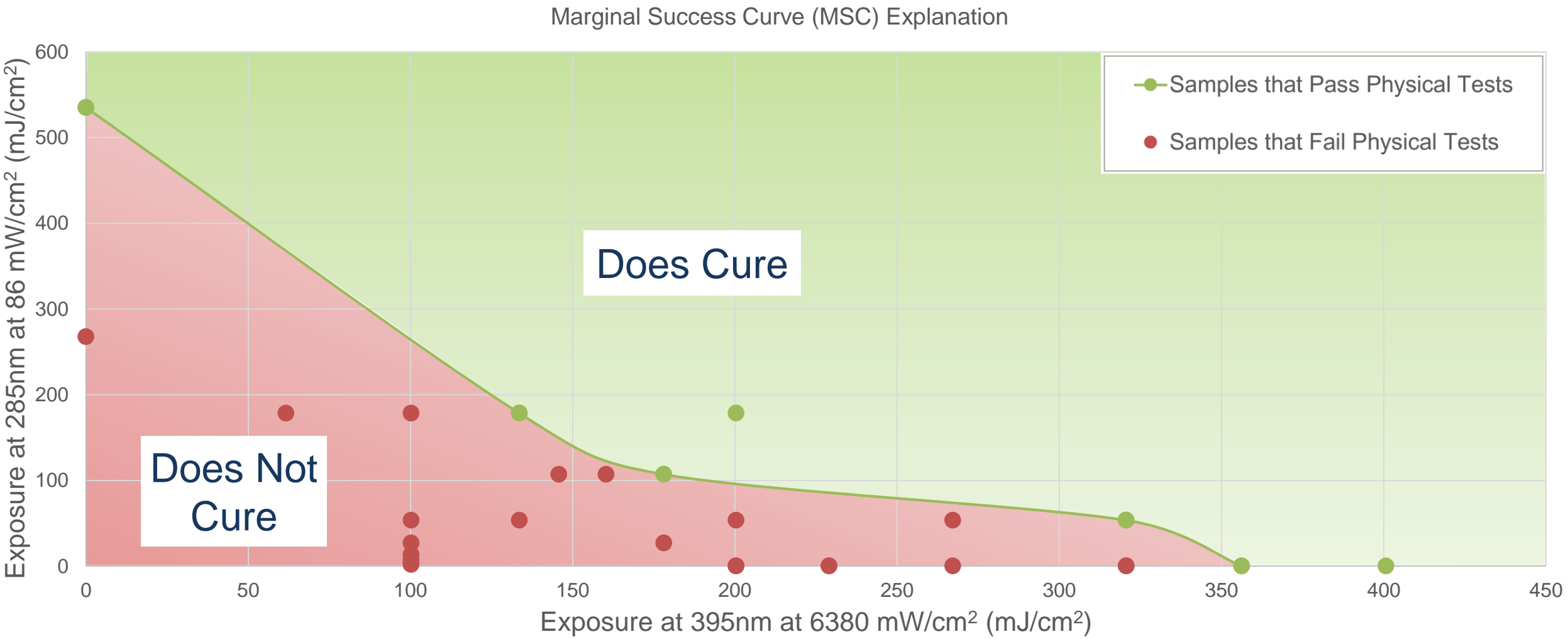
## Coatings C and D

- › Clear, 14  $\mu$ m (0.55mil)
- › Cured in air
- › Small amount of UVB (30-100 mJ/cm<sup>2</sup>) had significant impact on cure speed
- › Cured with only UVB (Coating D) at high exposure
- › Using more UVA energy means less UVB is necessary to cure, and vice versa

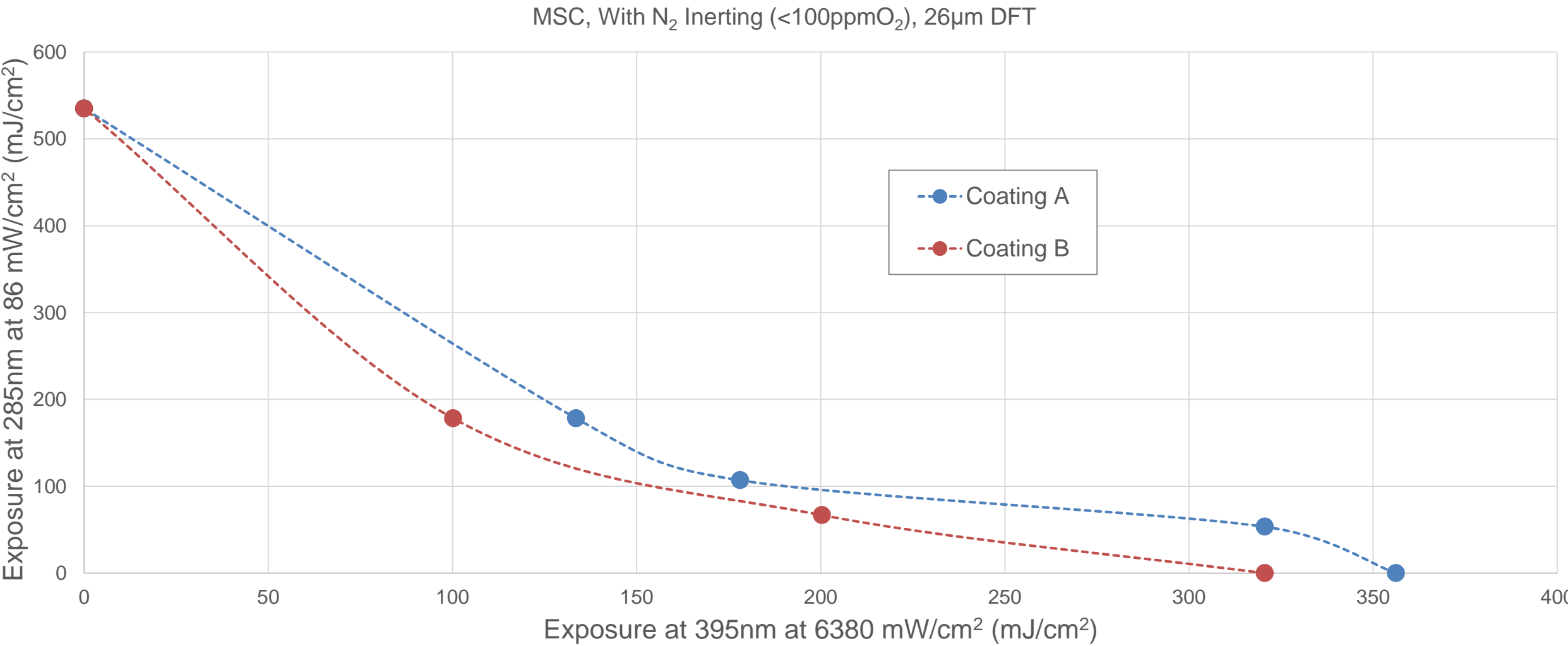




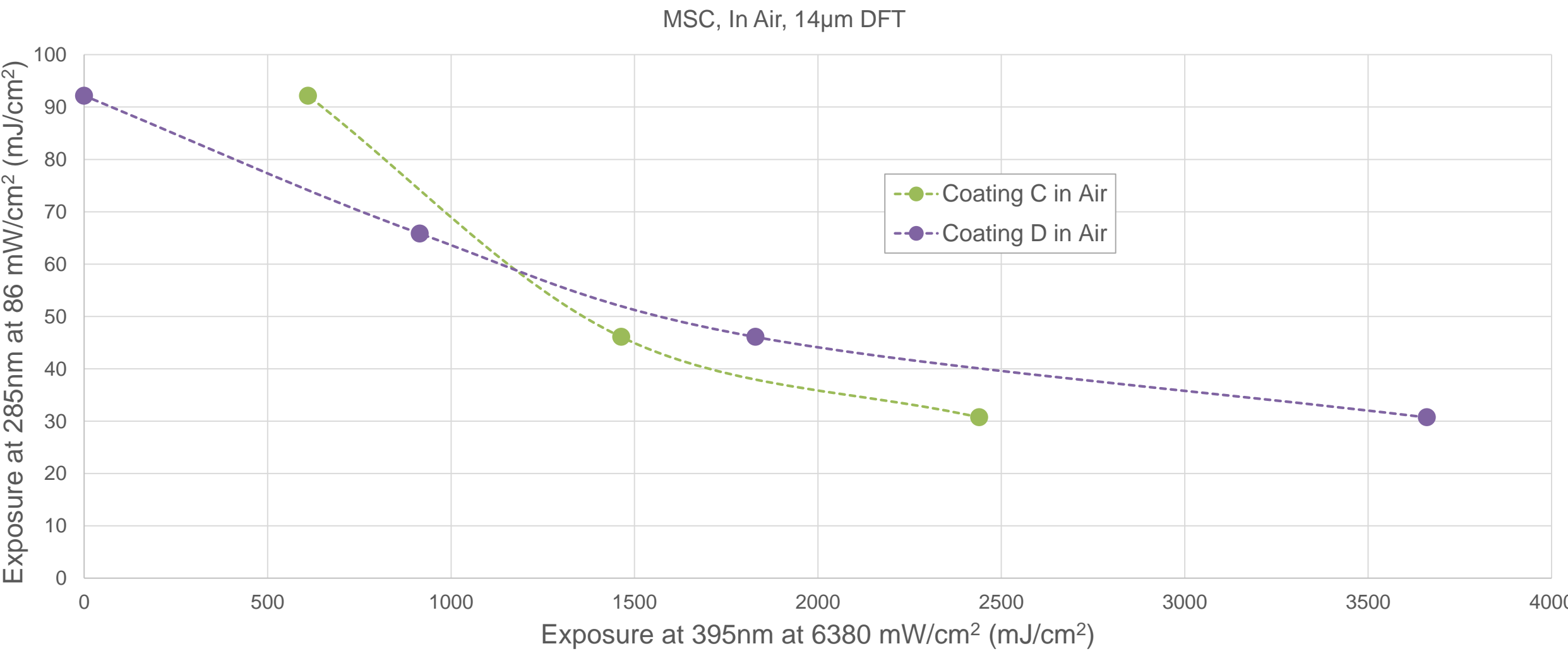
# RESULTS



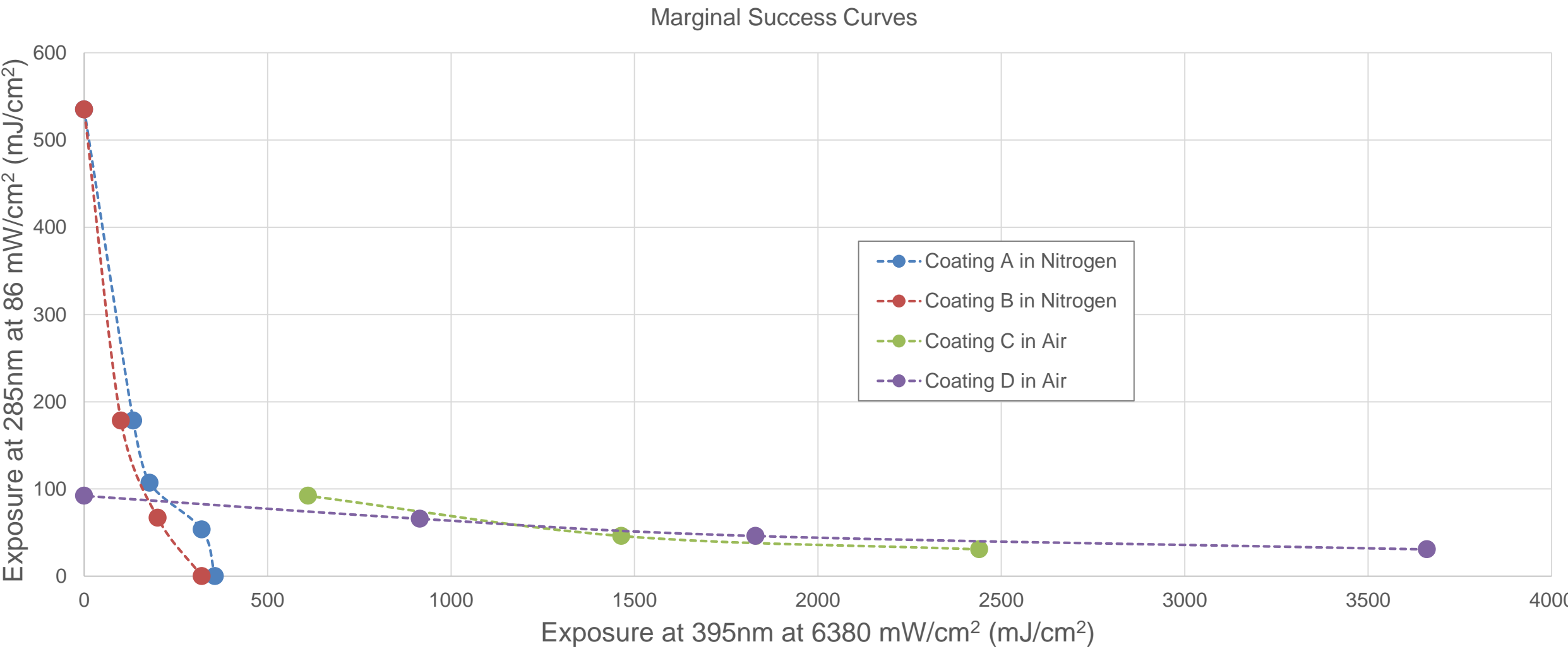
# RESULTS- COATINGS A AND B



# RESULTS- COATINGS C AND D



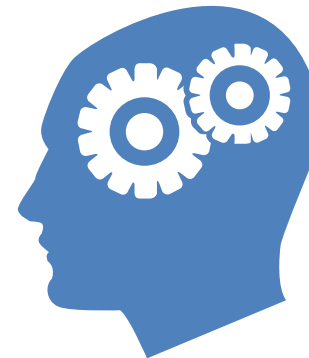
# RESULTS



# CONCLUSIONS

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- › Overcoming oxygen inhibition with LED is challenging while formulating to maintain all other properties that commercial formulations need to have—primarily adhesion and flexibility—without yellowing
- › It is difficult to formulate certain coatings to work successfully with UV LED—even combinations of wavelengths, contrasted with H-bulb at 300W/in
- › Exponentially more time consuming to characterize MSP and MSC of coating as more sources are added to exposure
- › Using nitrogen to overcome the problem is a valid option. It could be used to a lesser degree than here (at, say 5,000-1,000ppm O<sub>2</sub>) to have a positive effect



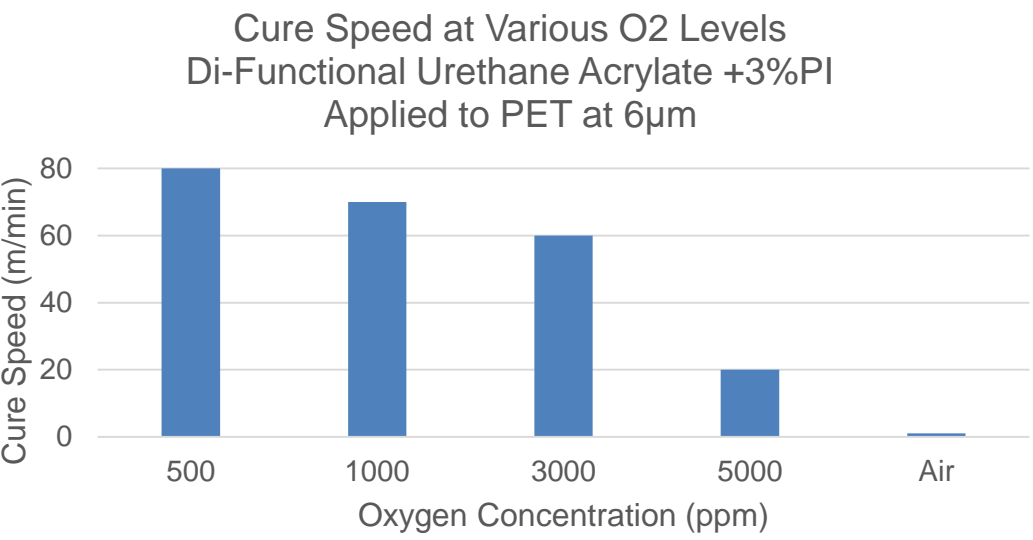
# DISCUSSION



# DISCUSSION- OVERCOMING OXYGEN INHIBITION

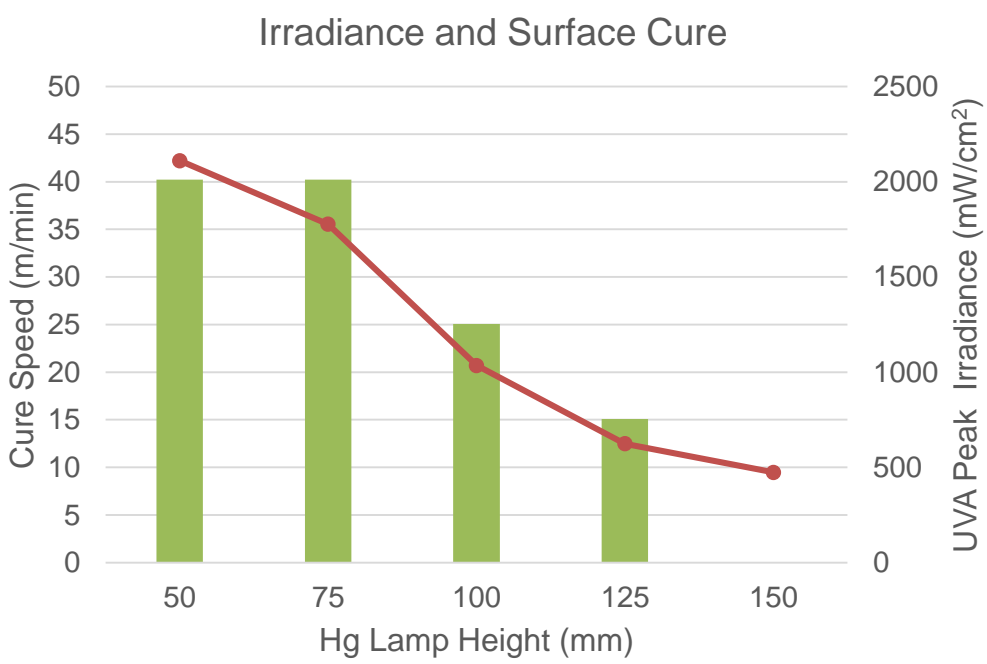
## Nitrogen Inerting

- › Significant improvements were noted at 1,000 and 3,000ppm oxygen with some coatings
- › Enables curing at extremely low film thickness (6µm)



## Peak Irradiance

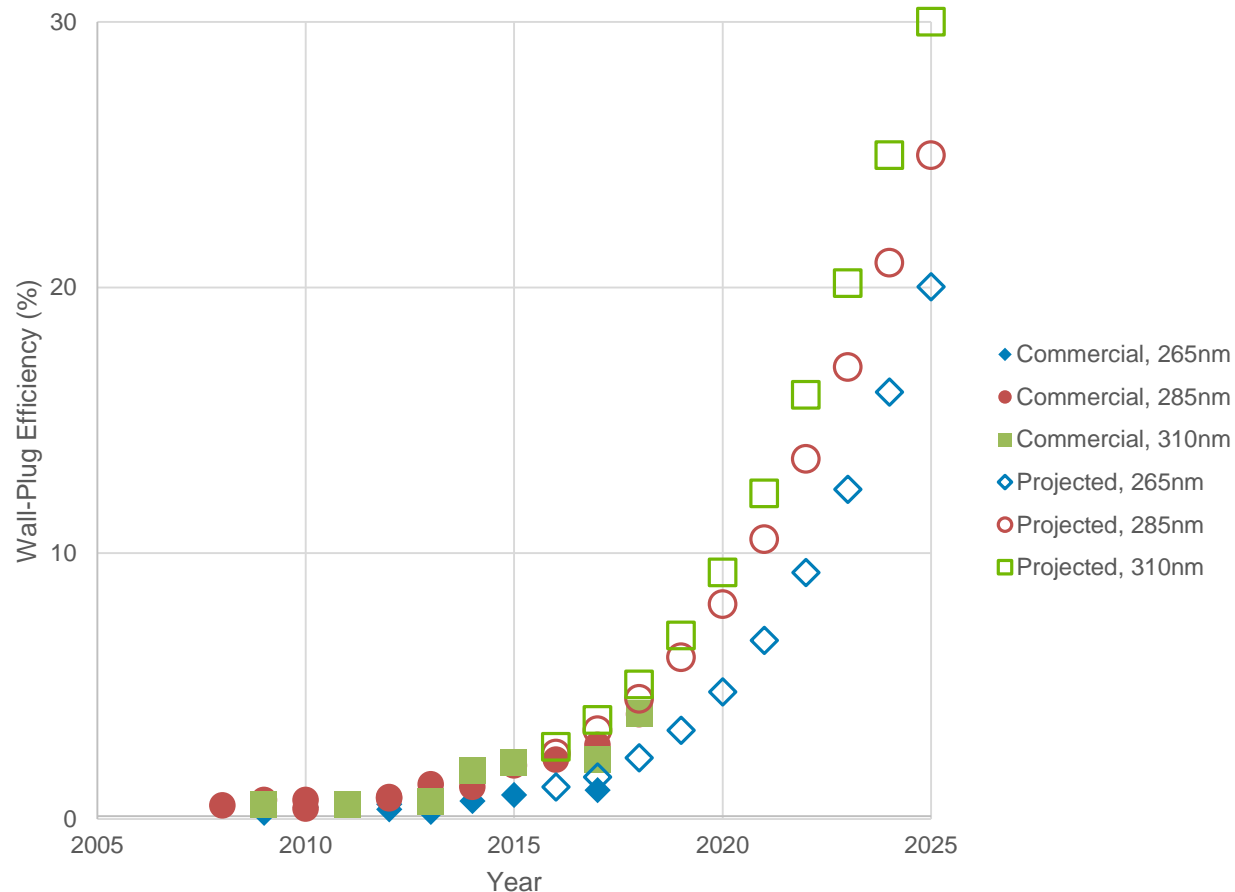
- › Increasing UV intensity (mW/cm<sup>2</sup>) can improve cure speed at the same energy level (mJ/cm<sup>2</sup>)



Skinner, Dawn. "Investigating the Practical Issues of Nitrogen Inerting in UV Curable Processes." Fusion UV Systems Inc.

# DISCUSSION- FUTURE OUTLOOK

WPEs of Commercial DUV LEDs



Kneissl, M., Seong, T., Han, J. et al. The emergence and prospects of deep-ultraviolet light-emitting diode technologies. Nat. Photonics 13, 233–244 (2019). <https://doi.org/10.1038/s41566-019-0359-9>

## Future Outlook

- › 310, 285, and 265nm emission bands are currently the most relevant for high-volume applications, and thus attract focused research and development effort
- › There could be a case made for 285nm LEDs overtaking 310nm LEDs in WPE due to high-volume applications in water treatment and disinfection
- › We should expect commercially available UVC and UVB LEDs with WPEs exceeding 10% by 2021
- › Higher WPEs → higher irradiance, which will help overcome oxygen inhibition and produce faster cure speeds
- › In the meantime, nitrogen inerting is an effective option when combined with LEDs
- › MSC guides equipment flexibility—Older lamps will not become obsolete quickly

# SPECIAL THANKS TO RAPID CURE TECHNOLOGIES

## Rapid Cure Technologies

- › Provided several formulations for testing via Dan Montoney
- › Formulate and manufacture paints, coatings, inks, adhesives, sealants, and resins for new startups, fortune 500 companies, and everything in between
- › Have competitive solutions using conventional (water-based, solvent-based, high-solids) and radiation curable (UV, E-beam, X-ray) chemistries



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1. Kneissl, M. & Rass, J. (eds) III-Nitride Ultraviolet Emitters—Technology and Applications (Springer, 2016).
2. Kneissl, M., Seong, T., Han, J. et al. The emergence and prospects of deep-ultraviolet light-emitting diode technologies. Nat. Photonics 13, 233–244 (2019). <https://doi.org/10.1038/s41566-019-0359-9>
3. Skinner, Brett. “Curing Traditional Formulations With Multi-Wavelength LEDs.” Radtech International UV & EB Technology Expo & Conference. Chicago, IL. 9 May 2018. Speaker Presentation
4. Skinner, Dawn. “Investigating the Practical Issues of Nitrogen Inerting in UV Curable Processes.” Fusion UV Systems Inc.

# QUESTIONS



# THANK YOU FOR YOUR ATTENTION

Acknowledgements: Darrin Leonhardt, Dawn Skinner, Eric Nelson

